

WEST**Freeform Search****Database:**

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JPO Abstracts Database
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Derwent World Patents Index
IBM Technical Disclosure Bulletins

Term:

16 and silicon

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10

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USPT,JPAB,EPAB,DWPI,TDBD	16 and silicon	18	<u>L7</u>
USPT,JPAB,EPAB,DWPI,TDBD	15 and crystal\$6	33	<u>L6</u>
USPT,JPAB,EPAB,DWPI,TDBD	catalyst\$3 near3 plasma	208	<u>L5</u>
USPT,JPAB,EPAB,DWPI,TDBD	12 and (plasma same metal)	19	<u>L4</u>
USPT,JPAB,EPAB,DWPI,TDBD	12 and plasma	55	<u>L3</u>
USPT,JPAB,EPAB,DWPI,TDBD	11 same silicon	627	<u>L2</u>
USPT,JPAB,EPAB,DWPI,TDBD	catalyst\$3 near3 crystal\$6	8998	<u>L1</u>

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Search Results - Record(s) 1 through 10 of 18 returned.

☐ 1. Document ID: US 6103558 A

L7: Entry 1 of 18

File: USPT

Aug 15, 2000

US-PAT-NO: 6103558

DOCUMENT-IDENTIFIER: US 6103558 A

TITLE: Process for producing electrooptical apparatus and process for producing driving substrate for electrooptical apparatus

Full	Title	Citation	Front	Review	Classification	Date	Reference	Claims	KWIC	Draw Desc	Image
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☐ 2. Document ID: US 5923962 A

L7: Entry 2 of 18

File: USPT

Jul 13, 1999

US-PAT-NO: 5923962

DOCUMENT-IDENTIFIER: US 5923962 A

TITLE: Method for manufacturing a semiconductor device

Full	Title	Citation	Front	Review	Classification	Date	Reference	Claims	KWIC	Draw Desc	Image
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☐ 3. Document ID: US 5851860 A

L7: Entry 3 of 18

File: USPT

Dec 22, 1998

US-PAT-NO: 5851860

DOCUMENT-IDENTIFIER: US 5851860 A

TITLE: Semiconductor device and method for producing the same

Full	Title	Citation	Front	Review	Classification	Date	Reference	Claims	KWIC	Draw Desc	Image
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☐ 4. Document ID: US 5843225 A

L7: Entry 4 of 18

File: USPT

Dec 1, 1998

US-PAT-NO: 5585291

DOCUMENT-IDENTIFIER: US 5585291 A

TITLE: Method for manufacturing a semiconductor device
containing a crystallization promoting material

Full	Title	Citation	Front	Review	Classification	Date	Reference	Claims	KWIC	Draw Desc	Image
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☐ 9. Document ID: US 5543352 A

L7: Entry 9 of 18

File: USPT

Aug 6, 1996

US-PAT-NO: 5543352

DOCUMENT-IDENTIFIER: US 5543352 A

TITLE: Method for manufacturing a semiconductor device using a
catalyst

Full	Title	Citation	Front	Review	Classification	Date	Reference	Claims	KWIC	Draw Desc	Image
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☐ 10. Document ID: US 5229347 A

L7: Entry 10 of 18

File: USPT

Jul 20, 1993

US-PAT-NO: 5229347

DOCUMENT-IDENTIFIER: US 5229347 A

TITLE: Catalyst for mild hydrocracking of cracked feedstocks
and method for its preparation

Full	Title	Citation	Front	Review	Classification	Date	Reference	Claims	KWIC	Draw Desc	Image
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Terms	Documents
16 and silicon	18

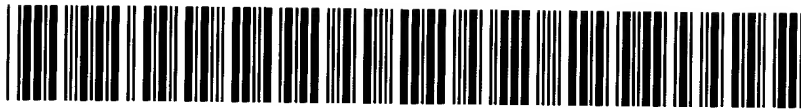
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No.	Doccode	Number of pages
1	CTNF	5
2	892	1
3	NFDR	1

Total number of pages: 7

Remarks:

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